

	Search Text	DBs
1	(microparticle near5 mark\$3) and laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
2	(264/400).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
3	microparticle near5 mark\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
4	laser near5 mark\$3 near5 print\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
5	(laser near5 mark\$3 near5 print\$3) same microparticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
6	(laser near5 marking near5 printing) same particle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
7	(microparticle near5 marking) same (print\$3 or laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
8	(plasma near5 etching) same laser same silicon\$1 same mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
9	(plasma near5 etching near5 laser) same silicon\$1 same mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
10	laser near5 marking near5 printing	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
11	microparticle near5 mark\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
12	microparticle near5 antioxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
13	(microparticle near5 mark\$3) and antioxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
14	microparticle near5 mark\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
15	(microparticle near5 mark\$3) and metal\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
16	(microparticle near5 mark\$3) and (vapor same deposit\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB

	Search Text	DBs
17	(microparticle near5 mark\$3) and (vapor same deposit\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
18	(microparticle near5 mark\$3) and metal\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
19	(219/121.68,121.69).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
20	((219/121.68,121.69).CCLS.) and (plasma near5 etch\$3) and laser and computer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
21	(plasma near5 etching) same silicon\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
22	(plasma near5 etching) near5 silicon\$3 near5 mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
23	((plasma near5 etching) near5 silicon\$3 near5 mask) same laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
24	((219/121.68,121.69).CCLS.) and (two adj3 lasers)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
25	microparticle same (liquid or medium) same (oxidant or antioxidant or anti-oxidant)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
26	(plasma near5 etch\$3) same laser same silicon\$1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
27	(plasma near5 etch\$3) same laser same silicon\$1 same mask\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
28	microparticle near5 (spray\$3 or paint\$3 or coat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
29	(microparticle near5 (spray\$3 or paint\$3 or coat\$3)) same mark\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
30	(microparticle near5 (spray\$3 or paint\$3 or coat\$3)) and anti-oxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
31	microparticle near5 mark\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
32	(microparticle near5 mark\$3) and (spray\$3 or paint\$3 or coat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB

	Search Text	DBs
33	microparticle near5 (mark\$3 or tagg\$3 or identif\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
34	(microparticle near5 (mark\$3 or tagg\$3 or identif\$4)) and (spray\$3 or paint\$3 or coat\$3) and anti-oxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
35	(microparticle near5 (mark\$3 or tagg\$3 or identif\$4)) and (spray\$3 or paint\$3 or coat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
36	(microparticle near5 (mark\$3 or tagg\$3 or identif\$4)) and (spray\$3 or paint\$3 or coat\$3) and anti-oxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
37	lacquer near5 anti-oxidant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB